

ABSTRACT OF THE DISCLOSURE

The main object of the present invention is to provide a method for manufacturing an EL element capable of forming thin light emitting layers with an even film thickness at the time of manufacturing an EL element having a plurality of light emitting layers and capable of simplifying the manufacturing process. In order to achieve the above object, the present invention provides A method for manufacturing an electroluminescent element comprising formation of a film of a light emitting layer constituting the electroluminescent element by a printing method, wherein the viscosity of the light emitting layer forming coating solution for forming the light emitting layer is 0.5 cP or more and 500 cP or less.